East Search

L Number	Hits	Search Text	DB	Time stamp
1	2536		USPAT;	2004/04/18 13:22
			US-PGPUB;	1000,000,000
			EPO; JPO;	
			DERWENT	
2	4924	(acid photoacid) adj generator	USPAT;	2004/04/18 13:23
			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
3	116371	(infrared IR) adj absorb\$3 (carbon adj	USPAT;	2004/04/18 13:24
		black)	US-PGPUB;	
			EPO; JPO;	· ·
_	_	("	DERWENT	
4	2	("4943511").PN.	USPAT;	2004/04/18 13:24
			US-PGPUB;	
			EPO; JPO;	
	11344	(infrared TD) near (absorbed)	DERWENT	2004/04/10 13 21
_	11344	(infrared IR) near (absorb\$4)	USPAT;	2004/04/18 13:21
			US-PGPUB;	
			EPO; JPO; DERWENT	
_	14081	\$5acid near generat\$4	USPAT;	2003/03/27 12:32
	14001	Pagera Hear Generacht	US-PGPUB;	2003/03/2/ 12:32
			EPO; JPO;	
			DERWENT	
_	3	dual adj polymer near binder	USPAT;	2003/03/27 12:39
		dan day porymer near prince	US-PGPUB;	2003,03/27 12.39
			EPO; JPO;	
-			DERWENT	
	3012981	polymer binder resist photoresist resin	USPAT;	2003/03/27.12:39
		polymer annual results processes access	US-PGPUB;	=====================================
			EPO; JPO;	
			DERWENT	
_	367	((infrared IR) near (absorb\$4)) and (\$5acid	USPAT;	2003/03/27 12:40
		near generat\$4) and (polymer binder resist	US-PGPUB;	
		photoresist resin)	EPO; JPO;	
			DERWENT	
-	55158	(phenol \$2cresol (p-hydroxy adj benzoic)	USPAT;	2003/03/27 13:16
		(2-naphthol)) and (catechol resorcinol	US-PGPUB;	
		hydroquinone (bisphenol adj A.u/c.)	EPO; JPO;	
		(bisphenol adj B.u/c.) trihydroxybenzene)	DERWENT	
-	250258	aldehyde formaldehyde acetaldehyde fural	USPAT;	2003/03/27 12:43
		benzaldehyde	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	117	(((infrared IR) near (absorb\$4)) and (\$5acid	USPAT;	2003/03/27 12:43
		near generat\$4) and (polymer binder resist	US-PGPUB;	
		photoresist resin)) and ((phenol \$2cresol	EPO; JPO;	
		(p-hydroxy adj benzoic) (2-naphthol)) and	DERWENT	
		(catechol resorcinol hydroquinone (bisphenol		
		adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene)) and (aldehyde		
		formaldehyde acetaldehyde fural benzaldehyde		
)		
_	167838	/ (carbon adj black) (pyridyl quinolinyl	USPAT;	2003/03/31 15:12
	10/030	benzoxazolyl thiazolyl benothiazolyl	US-PGPUB;	2003/03/31 13:12
		oxazolyl selenazoly)	EPO; JPO;	
] 1		STATESTITE BOXONGHOLY!	DERWENT	
_	51388	sulfonium sulfoxonium arsonium iodonium	USPAT;	2003/03/27 12:45
		diazonium bromonium selenonium phosphonium	US-PGPUB;	
		prosprostani	EPO; JPO;	
			DERWENT	
_	582115	(expos\$4 irradiat\$4 image-wise image) and	USPAT;	2003/03/27 12:46
	_	(develop\$3)	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	3251221	heat cure \$5bake \$5baking curing heating	USPAT;	2003/03/27 12:46
			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
	·	l		

-	79		USPAT;	2004/04/06 10:46
		(\$5acid near generat\$4) and (polymer binder	US-PGPUB;	
		resist photoresist resin)) and ((phenol	EPO; JPO;	
		\$2cresol (p-hydroxy adj benzoic)	DERWENT	i
		(2-naphthol)) and (catechol resorcinol		
		hydroquinone (bisphenol adj A.u/c.)		
		(bisphenol adj B.u/c.) trihydroxybenzene))		
		and (aldehyde formaldehyde acetaldehyde		
		fural benzaldehyde)) and ((carbon adj		
		black) (pyridyl quinolinyl benzoxazolyl		
		thiazolyl benothiazolyl oxazolyl selenazoly)		
!) and (sulfonium sulfoxonium arsonium		
		iodonium diazonium bromonium selenonium		
		phosphonium) and ((expos\$4 irradiat\$4		
		image-wise image) and (develop\$3)) and		
		(heat cure \$5bake \$5baking curing heating)		
	168946	(phenol \$2cresol (p-hydroxy adj benzoic)	HCDAT.	2003/03/27 13:17
-	100946	(2-naphthol)) and (catechol resorcinol	USPAT;	2003/03/2/ 13:1/
			US-PGPUB;	
		hydroquinone (bisphenol adj A.u/c.)	EPO; JPO;	
		(bisphenol adj B.u/c.) trihydroxybenzene)	DERWENT	
		same aldehyde formaldehyde acetaldehyde		
	0.455	fural benzaldehyde		
-	9655	1 1	USPAT;	2003/03/27 13:18
		(2-naphthol)) and (catechol resorcinol	US-PGPUB;	
		hydroquinone (bisphenol adj A.u/c.)	EPO; JPO;	
		(bisphenol adj B.u/c.) trihydroxybenzene)	DERWENT	
		same (aldehyde formaldehyde acetaldehyde		
		fural benzaldehyde)		
-	107		USPAT;	2003/03/27 13:53
		near generat\$4) and (polymer binder resist	US-PGPUB;	
		photoresist resin)) and ((phenol \$2cresol	EPO; JPO;	
		(p-hydroxy adj benzoic) (2-naphthol)) and	DERWENT	
		(catechol resorcinol hydroquinone (bisphenol		
		adj A.u/c.) (bisphenol adj B.u/c.)		
ļ		trihydroxybenzene) same aldehyde		
		formaldehyde acetaldehyde fural benzaldehyde		
) and ((carbon adj black) (pyridyl		
		quinolinyl benzoxazolyl thiazolyl		
		benothiazolyl oxazolyl selenazoly)) and		
	1	(sulfonium sulfoxonium arsonium iodonium		
		diazonium bromonium selenonium phosphonium)		
		and ((expos\$4 irradiat\$4 image-wise image)		
		and (develop\$3)) and (heat cure \$5bake		
		\$5baking curing heating)		
_	46		USPAT;	2003/03/27 14:09
	1	*****	US-PGPUB;	2003/03/27 14:03
			EPO; JPO;	
			DERWENT	
	L		DEKMENT	

	,,,,			
		((((infrared IR) near (absorb\$4)) and (\$5acid near generat\$4) and (polymer binder resist photoresist resin)) and ((phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene) same aldehyde formaldehyde acetaldehyde fural benzaldehyde) and ((carbon adj black) (pyridyl quinolinyl benzoxazolyl thiazolyl benothiazolyl oxazolyl selenazoly)) and (sulfonium sulfoxonium arsonium iodonium diazonium bromonium selenonium phosphonium) and ((expos\$4 irradiat\$4 image-wise image) and (develop\$3)) and (heat cure \$5bake \$5baking curing heating)) not ((((infrared IR) near (absorb\$4)) and (\$5acid near generat\$4) and (polymer binder resist photoresist resin)) and ((phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene)) and (aldehyde formaldehyde acetaldehyde fural benzaldehyde guinolinyl benzoxazolyl thiazolyl	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 15:22
		quinolinyl benzoxazolyl thiazolyl benothiazolyl oxazolyl selenazoly)) and (sulfonium sulfoxonium arsonium iodonium diazonium bromonium selenonium phosphonium) and ((expos\$4 irradiat\$4 image-wise image) and (develop\$3)) and (heat cure \$5bake		
-	1	\$5baking curing heating)) write-the-background adj mode	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 15:22
_	1	(write-the-image) adj mode	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 15:23
-	2	<pre>(write-the-background adj mode) ((write-the-image) adj mode)</pre>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 15:29
-	17	ARIAS-A ARIAS-ANDRE-LUIZ ARIAS-A-L ARIAS-L ARIAS-LUIS ARIAS-LUIZ-NEI ARIAS-L-N ARIAS-M ARIAS-MARJORIE PROVENZANO-MARIO-ITALO PROVENZANO-M-I	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 15:39
-	23813	cyclohexanone same solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/31 14:51
-	0	((bisphenol adj a.u/c. near2 formaldehyde) (m-cresol adj formaldehyde) (bisphenol adj a.u/cformaldehyde) (m-cresol-formaldehyde)) same (molecualar adj weight)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/31 15:19
-	189263	((bisphenol adj a.u/c. near2 formaldehyde) (m-cresol adj formaldehyde) (bisphenol adj a.u/cformaldehyde) (m-cresol-formaldehyde))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/15 15:55
-	156517	(develop\$4) same (cur\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 09:19
-	2255	((develop\$4) same (cur\$4)) and (novolak resol)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 11:49

-	527	(((develop\$4) same (cur\$4)) and (novolak resol)) and (onium (\$5acid near generat\$3))	USPAT; US-PGPUB; EPO; JPO;	2003/04/01 11:49
_	53	((((develop\$4) same (cur\$4)) and (novolak resol)) and (onium (\$5acid near generat\$3))) and ((infrared IR) near3	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/04/01 11:49
-	36	absorb\$3) (((((develop\$4) same (cur\$4)) and (novolak resol)) and (onium (\$5acid near generat\$3))) and ((infrared IR) near3	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/04/01 09:19
-	24035	absorb\$3)) and (curing cure) (develop\$4) same (cure curing cured)	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/04/01 09:19
_	1597	((develop\$4) same (cure curing cured)) and (novolak resol)	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/04/01 09:22
-	372	(((develop\$4) same (cure curing cured)) and (novolak resol)) and (onium (\$5acid near generat\$3))	DERWENT USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 09:25
-	29	((((develop\$4) same (cure curing cured)) and (novolak resol)) and (onium (\$5acid near generat\$3))) and ((infrared IR) near3	USPAT; US-PGPUB; EPO; JPO;	2003/04/01 11:39
-	3	absorb\$3) cure adj after adj development	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/04/01 11:48
-	10564	cur\$3 near3 develop\$4	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/04/01 11:49
-	_ 410	(cur\$3 near3 develop\$4) and (novolak resol)	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/04/01 11:49
-	130	((cur\$3 near3 develop\$4) and (novolak resol)) and (onium (\$5acid near generat\$3))	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/04/01 11:49
-	2	<pre>(((cur\$3 near3 develop\$4) and (novolak resol)) and (onium (\$5acid near generat\$3))) and ((infrared IR) near3 absorb\$3)</pre>	DERWENT USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 10:02
-	304	(resol resole) same (polyhydric)	USPAT; US-PGPUB; EPO; JPO;	2003/12/15 16:00
-	785	resorcinol same (resol resole)	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/12/17 11:44
-	154	(resol resole) same (polyhydroxy dihydroxy poly-hydroxy di-hydroxy)	DERWENT USPAT; US-PGPUB; EPO; JPO;	2003/12/17 12:42
-	2 . 6	(("5786125") or ("6042987")).PN. (((cur\$3 near3 develop\$4) and (novolak resol)) and (onium (\$5acid near generat\$3))) and ((infrared IR) near3 absorb\$3)	DERWENT USPAT; USPAT; US-PGPUB; EPO; JPO;	2003/12/17 12:42 2004/04/06 10:03
-	2	ep-0501433-\$.did. us-4943511-\$.did.	DERWENT USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:44

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-	140	((((infrared IR) near (absorb\$4)) and	USPAT;	2004/04/06 10:47
		(\$5acid near generat\$4) and (polymer binder	US-PGPUB;	
		resist photoresist resin)) and ((phenol	EPO; JPO;	
		\$2cresol (p-hydroxy adj benzoic)	DERWENT	
		(2-naphthol)) and (catechol resorcinol		
		hydroquinone (bisphenol adj A.u/c.)		
		(bisphenol adj B.u/c.) trihydroxybenzene))		
	}	and (aldehyde formaldehyde acetaldehyde		
		fural benzaldehyde)) and ((carbon adj		
		black) (pyridyl quinolinyl benzoxazolyl		
		thiazolyl benothiazolyl oxazolyl selenazoly)		
) and (sulfonium sulfoxonium arsonium		
		iodonium diazonium bromonium selenonium		
		phosphonium) and ((expos\$4 irradiat\$4		
	1	image-wise image) and (develop\$3)) and		
		(heat cure \$5bake \$5baking curing heating)		2221/21/25 22 12
-	0	ep-0501433-\$.did.	USPAT;	2004/04/06 12:42
	1		US-PGPUB;	
			EPO; JPO;	
	2	ep-501433-\$.did.	DERWENT	2004/04/06 12:42
-	4	cp-301±33-\$.α1α.	USPAT; US-PGPUB;	2004/04/00 12:42
			EPO; JPO;	
			DERWENT	
1 -	4	ep-501433-\$.did. us-4943511-\$.did.	USPAT;	2004/04/06 12:44
	1	op striss quara. as is is is in the quara.	US-PGPUB;	2001,01,00 12.44
			EPO; JPO;	
			DERWENT	
_	0	(ep-501433-\$.did. us-4943511-\$.did.) and	USPAT;	2004/04/06 12:45
	_	(infrared IR)	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
_	0	(ep-501433-\$.did. us-4943511-\$.did.) and	USPAT;	2004/04/06 12:45
		(absorber)	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	2278370	polymer binder resist photoresist	USPAT;	2004/04/06 12:45
			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	110785	((infrared IR) adj absorber) (carbon adj	USPAT;	2004/04/06 12:46
		black)	US-PGPUB;	
			EPO; JPO;	
	15304	(photoacid acid) adj generat\$3	DERWENT	2004/04/05 32 55
-	15324	(photoacid acid) adj generats3	USPAT;	2004/04/06 12:46
			US-PGPUB; EPO; JPO;	
			DERWENT	
-	728	(polymer binder resist photoresist) and	USPAT;	2004/04/06 12:46
		(((infrared IR) adj absorber) (carbon adj	US-PGPUB;	
		black)) and ((photoacid acid) adj generat\$3)	EPO; JPO;	
]	DERWENT	
-	395417	cresol phenol p-hydroxybenzoic (p-hydroxy	USPAT;	2004/04/06 12:48
		adj benzoic) catechol resorcinol	US-PGPUB;	
		hydroquinone bisphenol trihydroxybenzene	EPO; JPO;	
			DERWENT	
-	190479	formaldehyde acetaldehyde fural benzaldehyde	USPAT;	2004/04/06 12:48
			US-PGPUB;	
			EPO; JPO;	
	225	(nolymon binder	DERWENT	2004/04/05 22 52
-	328	((polymer binder resist photoresist) and	USPAT;	2004/04/06 12:48
		(((infrared IR) adj absorber) (carbon adj	US-PGPUB;	
		black)) and ((photoacid acid) adj generat\$3)) and (cresol phenol	EPO; JPO; DERWENT	
		p-hydroxybenzoic (p-hydroxy adj benzoic)	DEKMENI	
		catechol resorcinol hydroquinone bisphenol		
		trihydroxybenzene) and (formaldehyde		
		acetaldehyde fural benzaldehyde)		
	1	1	I	L

_	275	(((polymer binder resist photoresist) and	USPAT;	2004/04/06 12:48
		(((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj	US-PGPUB; EPO; JPO;	
		generat\$3)) and (cresol phenol	DERWENT	
		p-hydroxybenzoic (p-hydroxy adj benzoic) catechol resorcinol hydroquinone bisphenol		
		trihydroxybenzene) and (formaldehyde		
		acetaldehyde fural benzaldehyde)) and develop\$4		
-	232	1	USPAT;	2004/04/06 12:49
		(((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj	US-PGPUB; EPO; JPO;	
		generat\$3)) and (cresol phenol	DERWENT	
		p-hydroxybenzoic (p-hydroxy adj benzoic) catechol resorcinol hydroquinone bisphenol		
		trihydroxybenzene) and (formaldehyde		
		acetaldehyde fural benzaldehyde)) and develop\$4) and (cur\$5)		
_	6568715	1 · · · · · · · · · · · · · · · · · · ·	USPAT;	2004/04/06 12:50
		(post adj bak\$4)	US-PGPUB; EPO; JPO;	
			DERWENT	
-	275	1 1 1 1 2	USPAT;	2004/04/06 12:50
		(((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj	US-PGPUB; EPO; JPO;	
		generat\$3)) and (cresol phenol p-hydroxybenzoic (p-hydroxy adj benzoic)	DERWENT	
		catechol resorcinol hydroquinone bisphenol		
	,	trihydroxybenzene) and (formaldehyde acetaldehyde fural benzaldehyde)) and		
		develop\$4) and (cur\$5 heat\$3 bak\$4 postbak\$4		
_	344633	<pre>post-bak\$4 (post adj bak\$4)) develop\$4 same (cur\$5 heat\$3 bak\$4 postbak\$4</pre>	USPAT;	2004/04/06 13:06
	311003	post-bak\$4 (post adj bak\$4))	US-PGPUB;	2001,01,00 15.00
			EPO; JPO; DERWENT	
-	2	us-4943511-\$.did.	USPAT;	2004/04/06 13:02
	¢)		US-PGPUB; EPO; JPO;	
	0		DERWENT	2004/04/06 12 05
_	0	(alizarin adj yellow adj "A" adj dye) same (infrared IR)	USPAT; US-PGPUB;	2004/04/06 13:05
			EPO; JPO; DERWENT	
-	2	alizarin adj yellow adj "A" adj dye	USPAT;	2004/04/06 13:05
			US-PGPUB; EPO; JPO;	
			DERWENT	
-	180	alizarin adj yellow	USPAT; US-PGPUB;	2004/04/06 13:05
			EPO; JPO;	
_	0	(alizarin adj yellow) same (infrared IR)	DERWENT USPAT;	2004/04/06 13:06
		, , , , , , , , , , , , , , , , , , ,	US-PGPUB;	
			EPO; JPO; DERWENT	
-	243	(((((polymer binder resist photoresist) and	USPAT;	2004/04/06 13:22
		(((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj	US-PGPUB; EPO; JPO;	
		generat\$3)) and (cresol phenol p-hydroxybenzoic (p-hydroxy adj benzoic)	DERWENT	
		catechol resorcinol hydroquinone bisphenol		
		trihydroxybenzene) and (formaldehyde acetaldehyde fural benzaldehyde)) and		
		develop\$4) and (cur\$5 heat\$3 bak\$4 postbak\$4		
		post-bak\$4 (post adj bak\$4))) and (develop\$4 same (cur\$5 heat\$3 bak\$4 postbak\$4		
		post-bak\$4 (post adj bak\$4)))	wan.	2004/04/25 55 55
-	11151	after adj develop\$3	USPAT; US-PGPUB;	2004/04/06 13:22
			EPO; JPO;	
			DERWENT	

- 27 ((((((polymer binder resist photoresist) and (((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj generat\$3)) and (cresol phenol p-hydroxybenzoic (p-hydroxy adj benzoic) catechol resorcinol hydroquinone bisphenol trihydroxybenzene) and (formaldehyde acetaldehyde fural benzaldehyde)) and develop\$4) and (cur\$5 heat\$3 bak\$4 postbak\$4 post-bak\$4 (post adj bak\$4))) and (develop\$4 same (cur\$5 heat\$3 bak\$4 postbak\$4 post-bak\$4 (post adj bak\$4))) and (after adj develop\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 13:22
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